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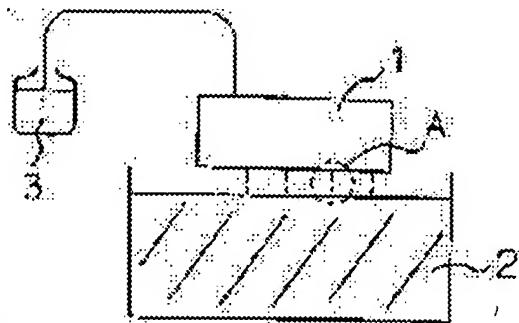
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(54) METHOD FOR MANUFACTURING MICROCAPSULE AND MICROCAPSULE  
OBTAINABLE THEREFROM AND APPARATUS FOR MANUFACTURING THE SAME

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a method for manufacturing microcapsules which are controlled in grain size and film thickness and have excellent performance, such as controllability of the time for releasing core materials to an external environment and releasing speed with high accuracy.

SOLUTION: This method for manufacture consists in supplying the whole or a part of the materials of at least one member constituting the microcapsules by an ink jet method. More particularly, the method for using the liquid containing the whole or the part of the materials described above as a discharge material and discharging and supplying this discharge material from an inkjet type head to the liquid to be discharged is adequately adopted.



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